

CAPITAL MARKETS DAY 2020

INSIGHTS BONDER

September 24, 2020

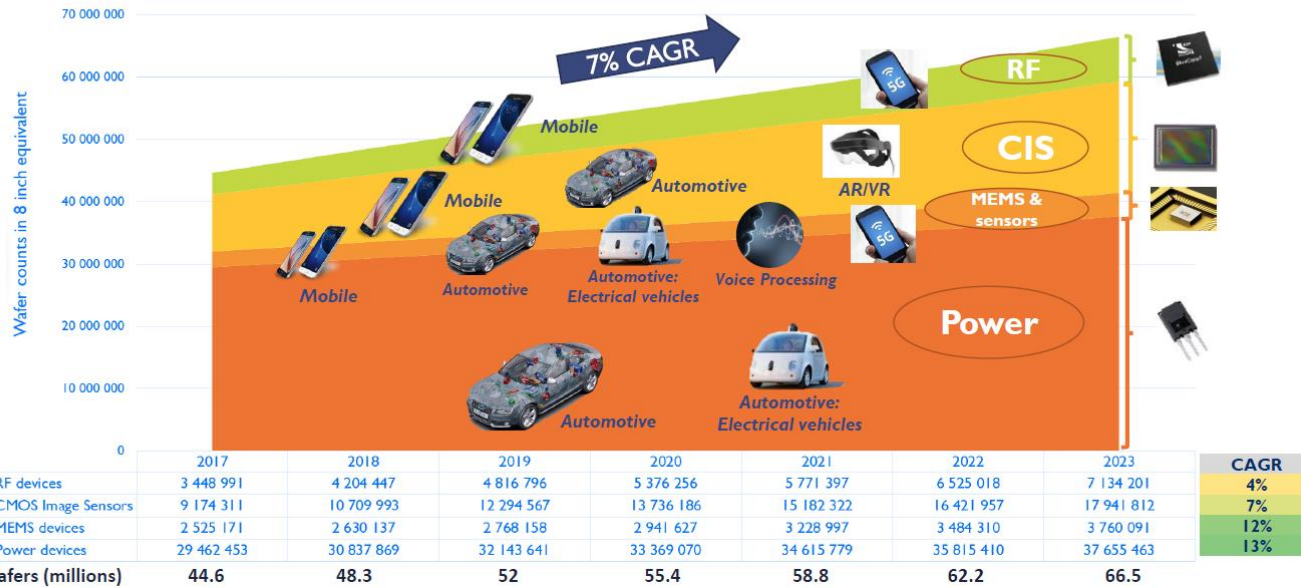
Stefan Lutter, Business Unit Manager Bonder



MORE THAN MOORE MARKET AND TECHNOLOGY TRENDS – APPLICATION DRIVERS FOR WAFER BONDING

- + Demand for “More than Moore” devices is expected at CAGR (2017-23) of 4 - 13% by Yole Développement
- + Wafer to Wafer (W2W) and Die to Wafer (D2W) bonding is required in many of these applications – see examples below

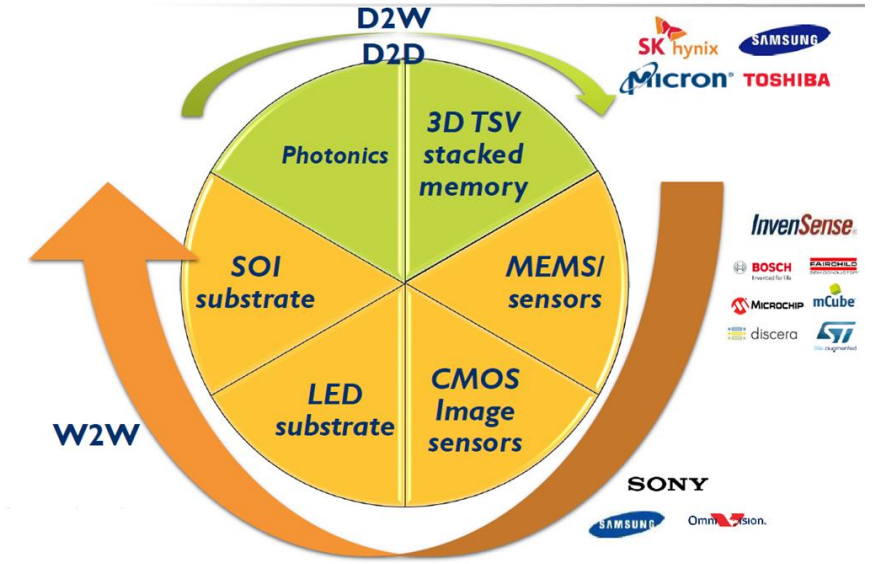
**Overall wafer demand for More than Moore devices
Breakdown by More than Moore application - in 8 inch eq**



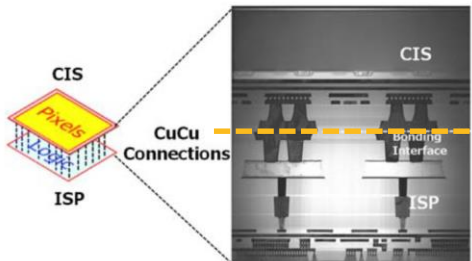
Source: Yole (2018, 2019)

APPLICATIONS REQUIRING PERMANENT BONDING

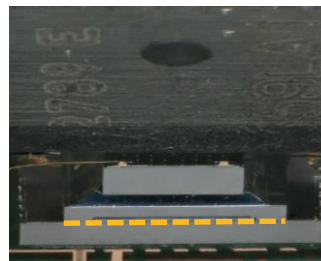
W2W Assembly technology used for More than More applications



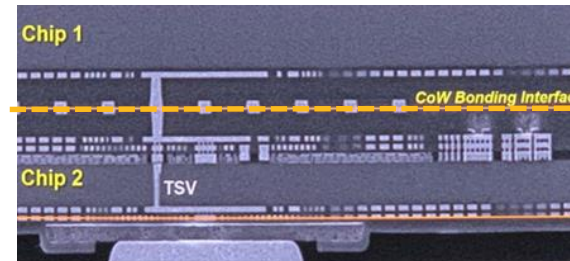
YOLO



Sony CMOS Image Sensor (CIS)
Source: Sony (2019)



InvenSense 7-axis MEMS
Source: SystemPlus (2017)



tsmc SoIC™ chip with 4µm TSVs and pitch of 9µm
Source: Techsearch (2020)



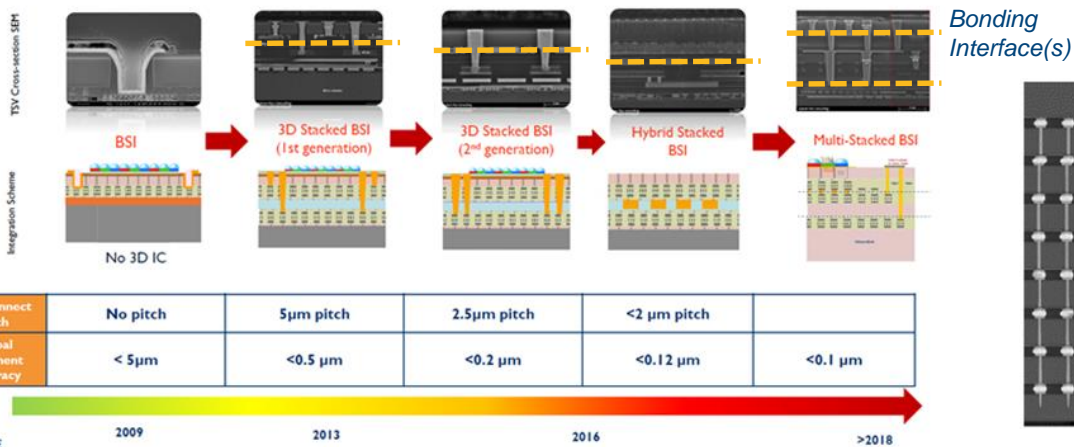
YOLO

MORE THAN MOORE MARKET AND TECHNOLOGY TRENDS

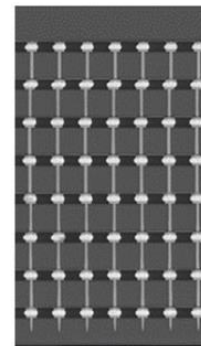
– 2.5D AND 3D STACKING TECHNOLOGY

- + 2.5D and 3D requires temporary bonding for wafer thinning as well as D2W or W2W bonding
- + D2W bonding enables heterogeneous integration, high yield is achieved by stacking known good dies (KGD)
- + Hybrid bonding will be the main enabler for pitch scaling (TSV and μ bump \rightarrow Cu/Cu interconnects = hybrid bonding)
 - Used for latest generations of CMOS image sensors since 2017
 - Will be used for other new 3D devices by IDMs and foundries
- + Equipment market is forecasted at CAGR (2018-25) of ~25% by Yole Développement

BSI CIS



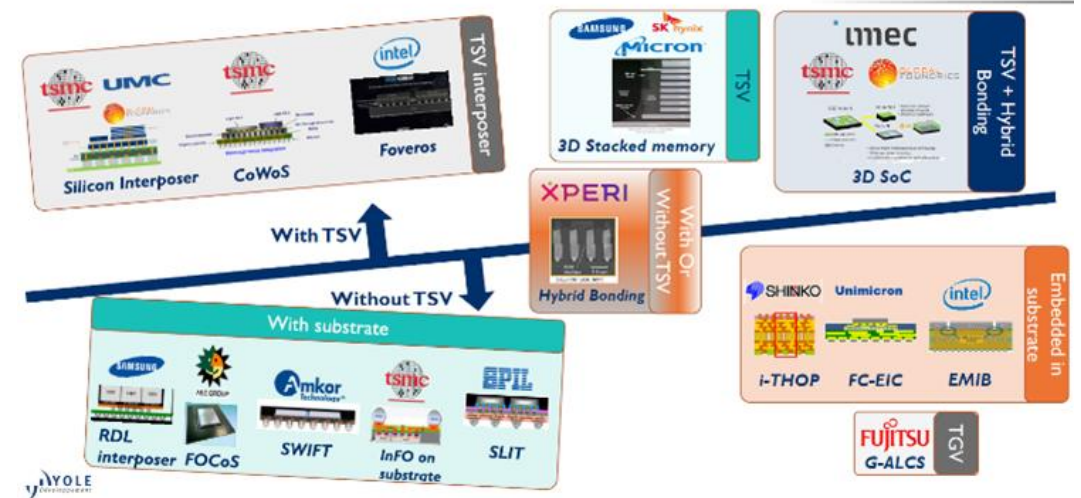
	No 3D IC	3D Stacked BSI (1st generation)	3D Stacked BSI (2nd generation)	Hybrid Stacked BSI	Multi-Stacked BSI
Interconnect Pitch	No pitch	5 μ m pitch	2.5 μ m pitch	<2 μ m pitch	<0.1 μ m
Global alignment Accuracy	< 5 μ m	<0.5 μ m	<0.2 μ m	<0.12 μ m	<0.1 μ m



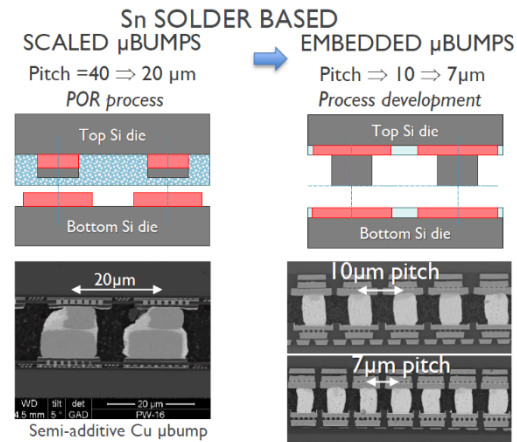
8GB HBM2 (3D memory)
Source: Samsung

2.5D & 3D STACKING TECHNOLOGIES

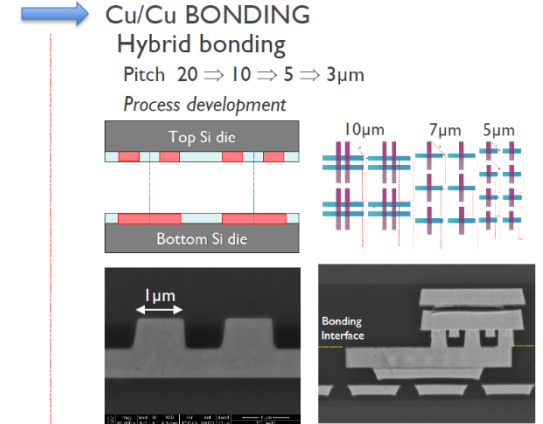
With / Without TSV. Foundries VS OSATs battle



Source: Yole (2018)



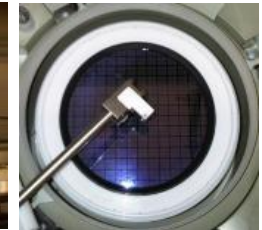
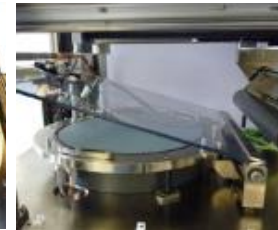
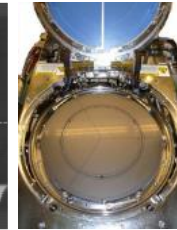
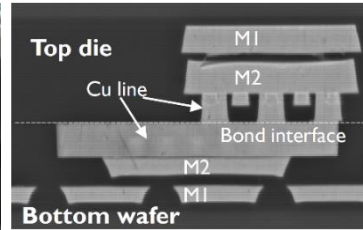
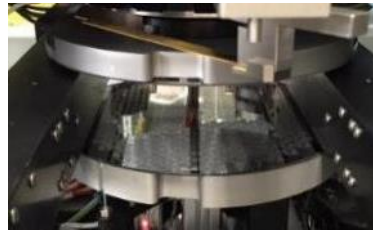
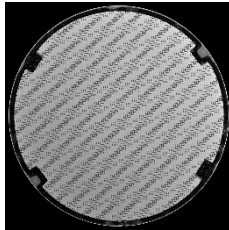
Source: imec (2020)



Business Unit Bonder

More than Moore – MEMS and related

More than Moore - 2.5D and 3D



Semi-Automated Bonders

Automated Permanent Bonders

Automated Temporary Bonders, Debonders and Cleaners



SB6/8 Gen2 (20kN)



XB8 (100kN)



XBS200
W2W Bonder



XBS300
W2W / collective D2W Bonder



XBS300
Temporary
Bonder



XBC300 Gen2
Debonder (mechanical / laser)
and Cleaner

Comment / USP

- Large installed base
- Supports all traditional processes

Supports new high force / high end processes

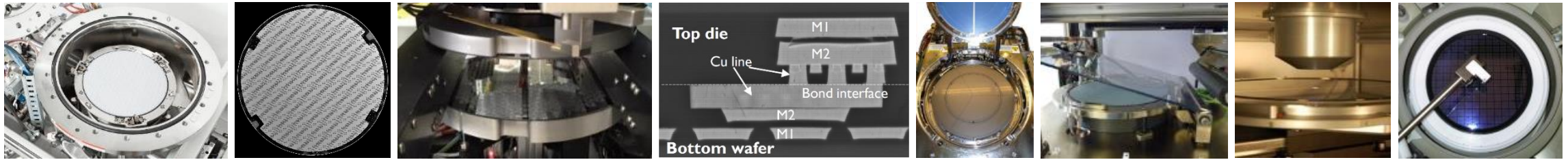
Fixture-less aligned wafer handling for best cost of ownership

<100nm overlay to support pitch scaling trend in hybrid bonding

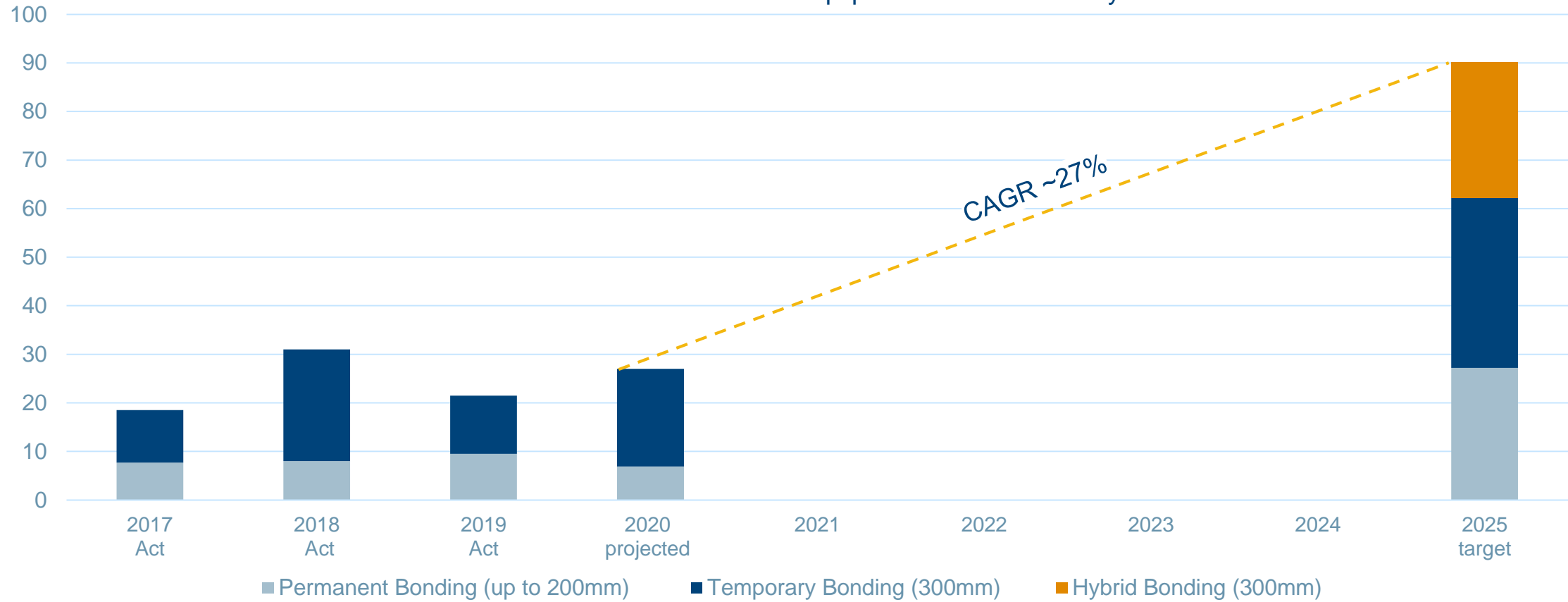
- Large installed base with ~40-50%¹⁾ market share for 2.5D and 3D memory
- Technology enabler applications such as CIS, FO-WLP
- Started transition from mechanical- to laser debonding for next generation of devices

1) SÜSS internal estimation

GROWTH POTENTIAL – ON TRACK WITH SUSS STRATEGY 2025 PROJECTION



Sales Revenue Bonder Equipment €M – most likely scenario



A close-up photograph of a hand holding a black marker, writing the words "Thank you!" in a cursive script on a white surface. The marker is positioned at the end of the exclamation point.

Thank you!